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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT: Hyungjun KIM et al.

CONFIRM. NO. 3395

SERIAL NO.: 10/699,226

ART UNIT: 1762

FILED: 10/31/2003

EXAMINER: Bret P. CHEN

TITLE: PLASMA ENHANCED ALD OF TANTALUM NITRIDE AND BILAYER

ATTORNEY DOCKET NO.: YOR920030208US1

Mail Stop AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

SUPPLEMENTAL AMENDMENT UNDER 37 C.F.R. 1.116

Responsive to the final Office Action of May 31, 2006,
and supplemental to the amendment mailed on August 31, 2006
(and filed on September 5, 2006), please reconsider this
application in view of the following:

Listing of and Amendments to Claims Page 2

Remarks Page 6

Certificate of Mailing

I hereby certify that this correspondence is being
deposited with the United States Postal Service as first
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October 2, 2006
Date

David Rhee
Name of Person Making Deposit